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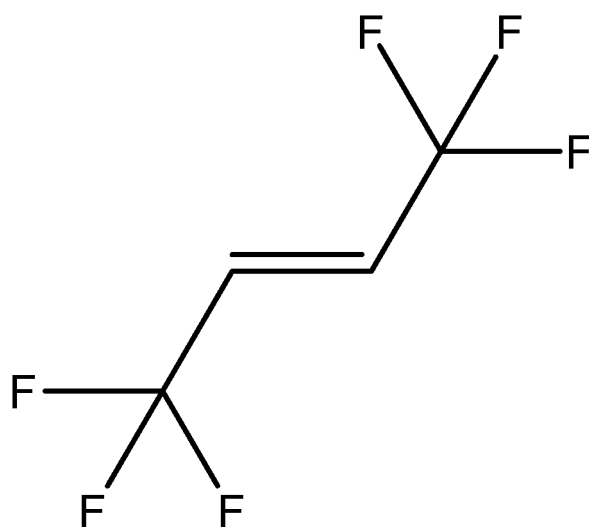


FIG 1

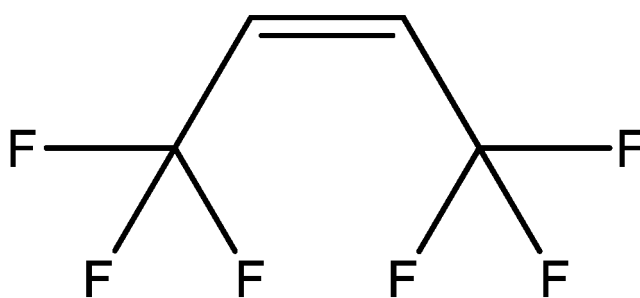


FIG 2

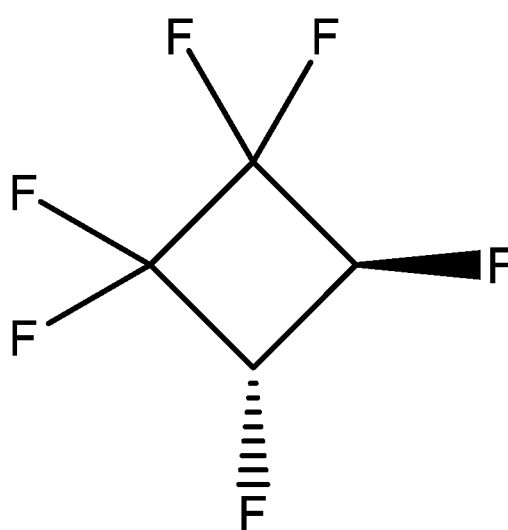


FIG 3

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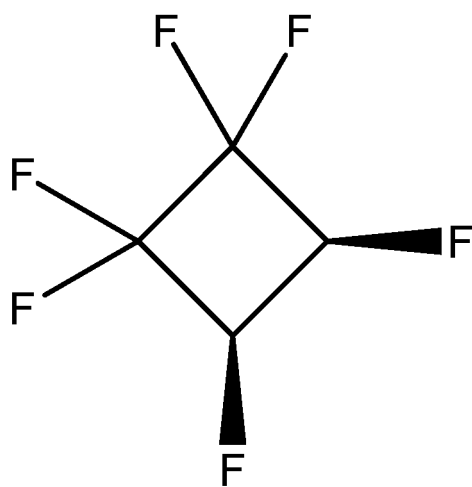


FIG 4

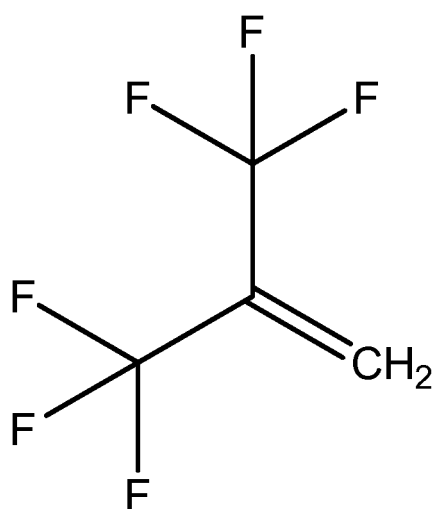


FIG 5

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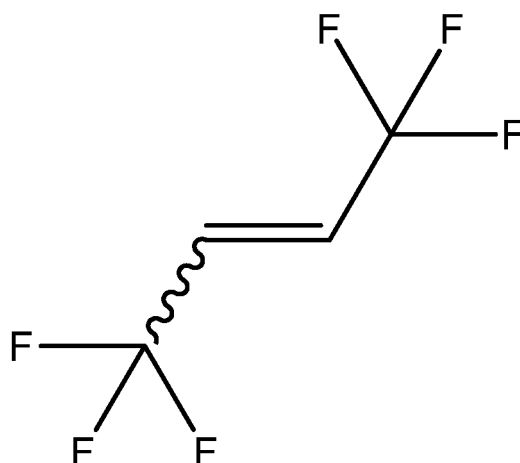


FIG 6

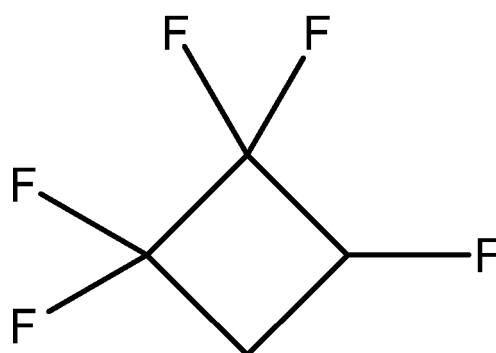


FIG 7

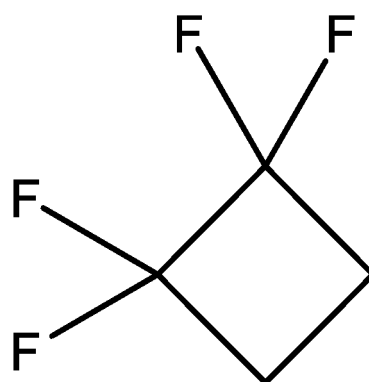


FIG 8

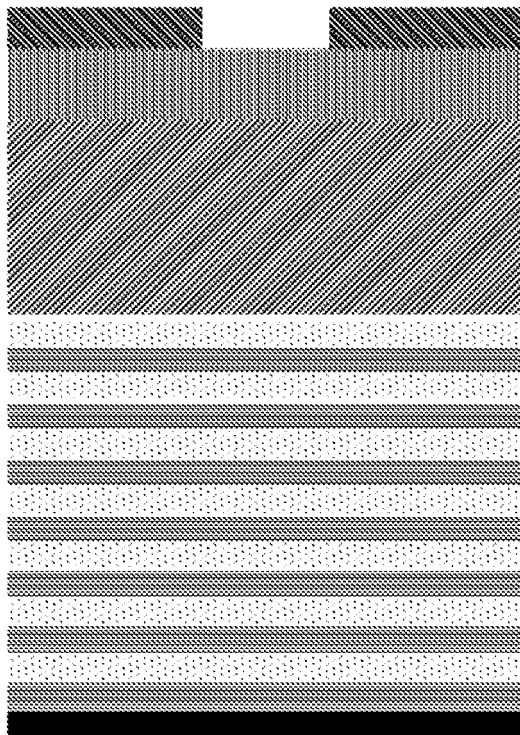
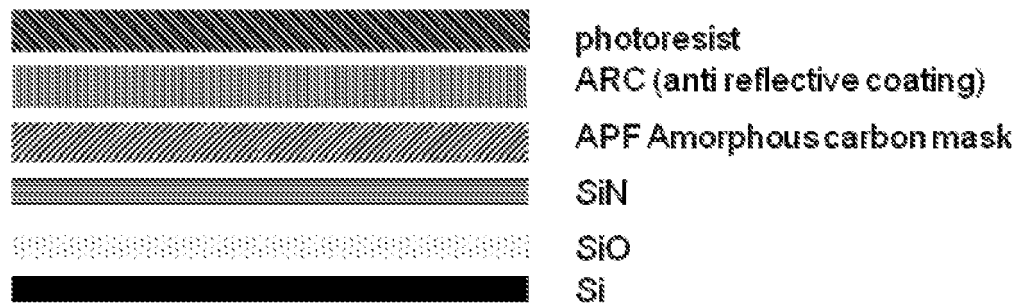


FIG 9

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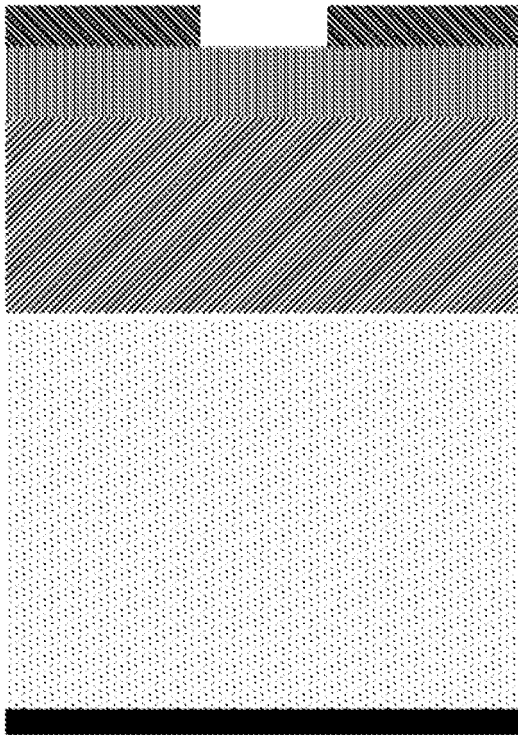
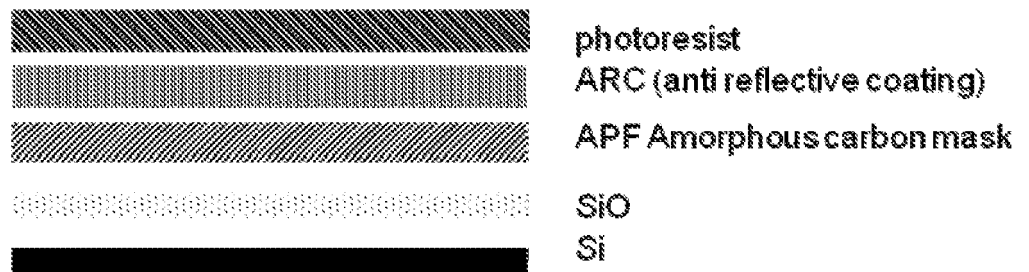


FIG 10

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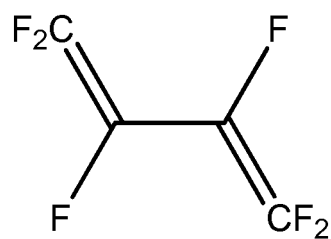
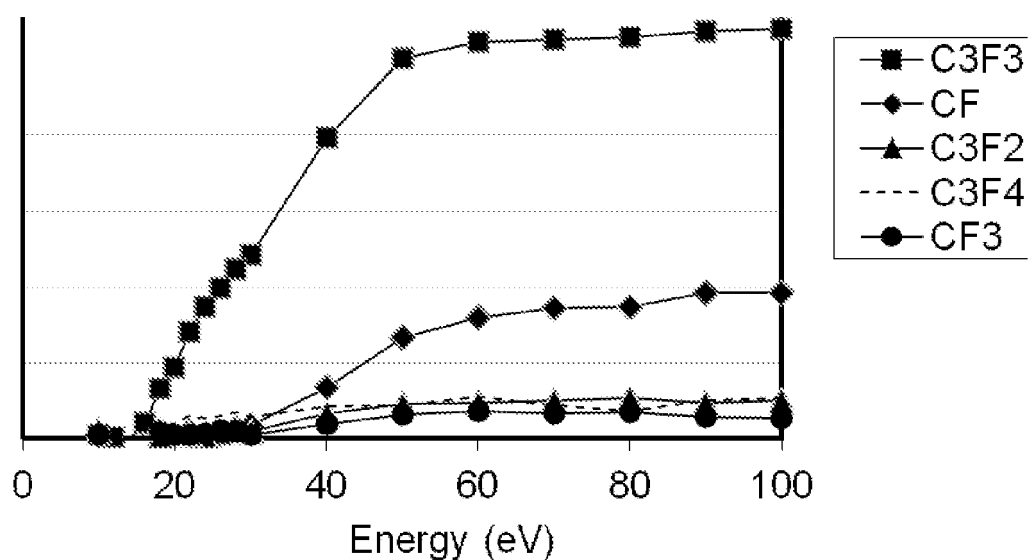


FIG 11

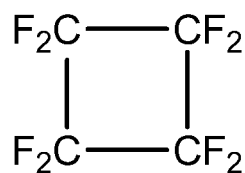
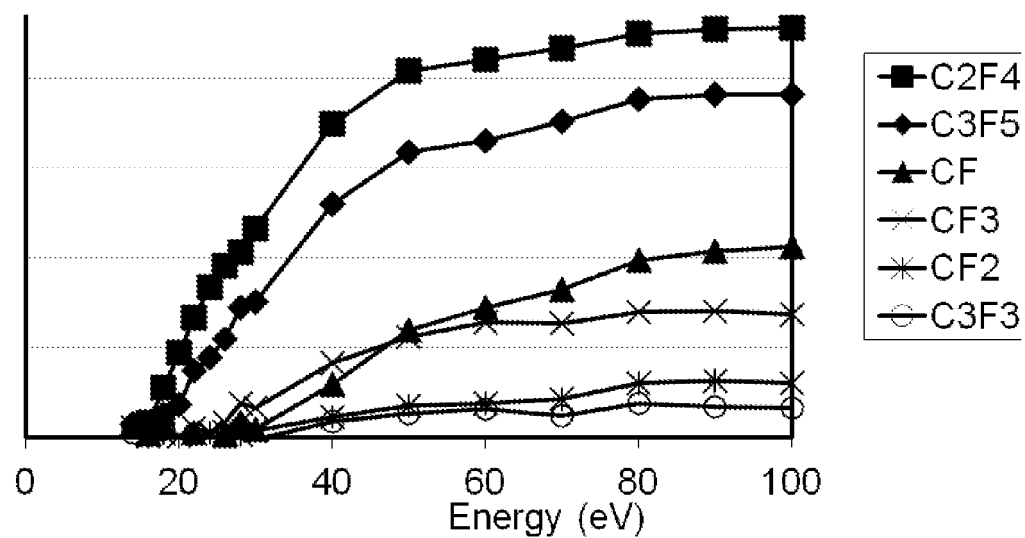


FIG 12

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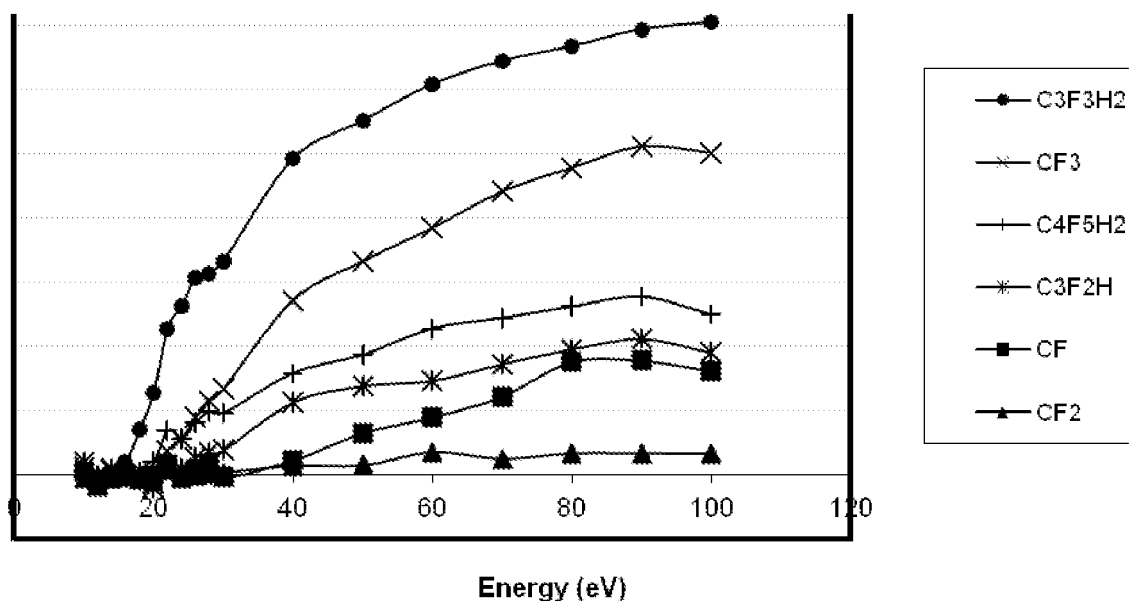


FIG 13

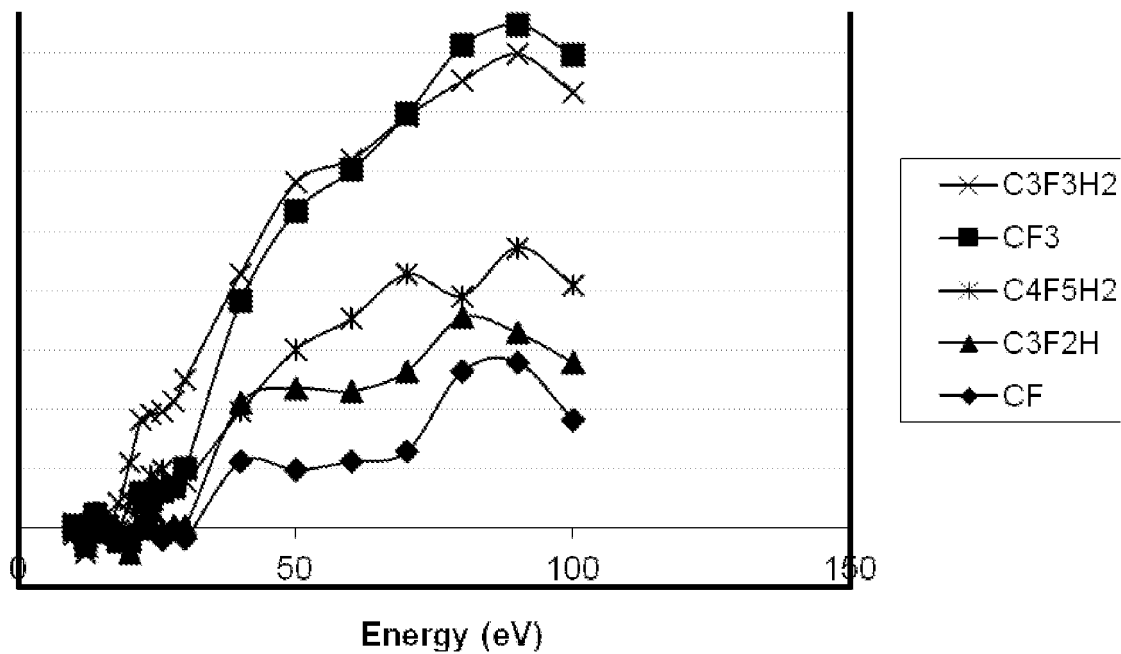


FIG 14

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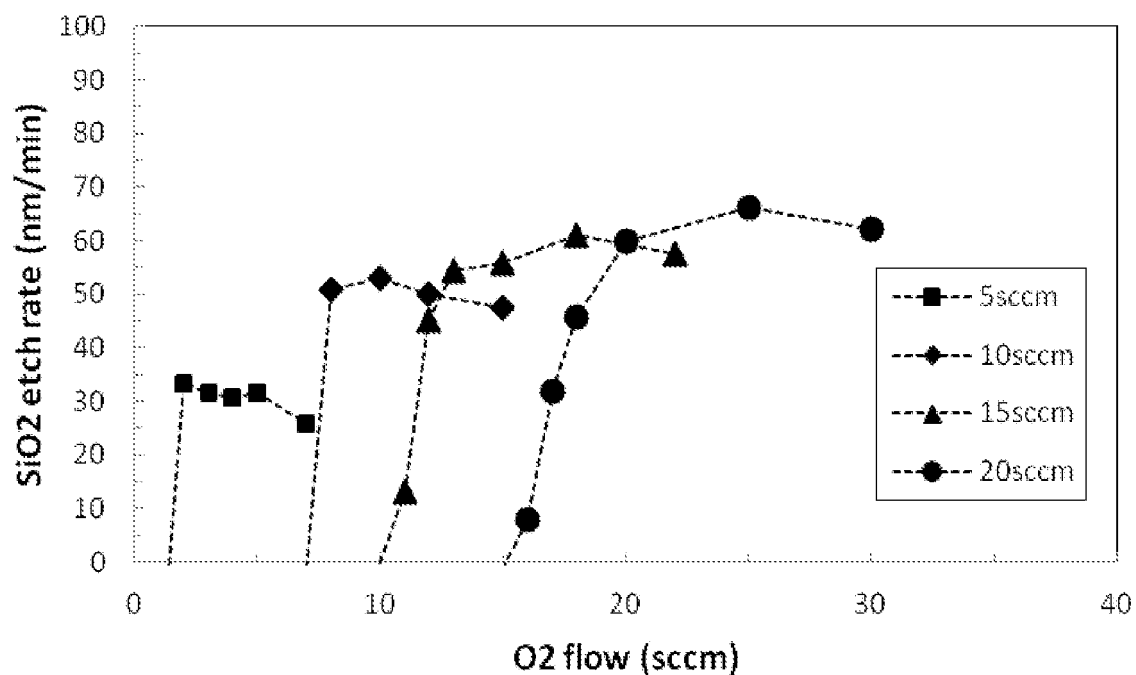
SiO₂ etch rate vs O₂ flow

FIG 15

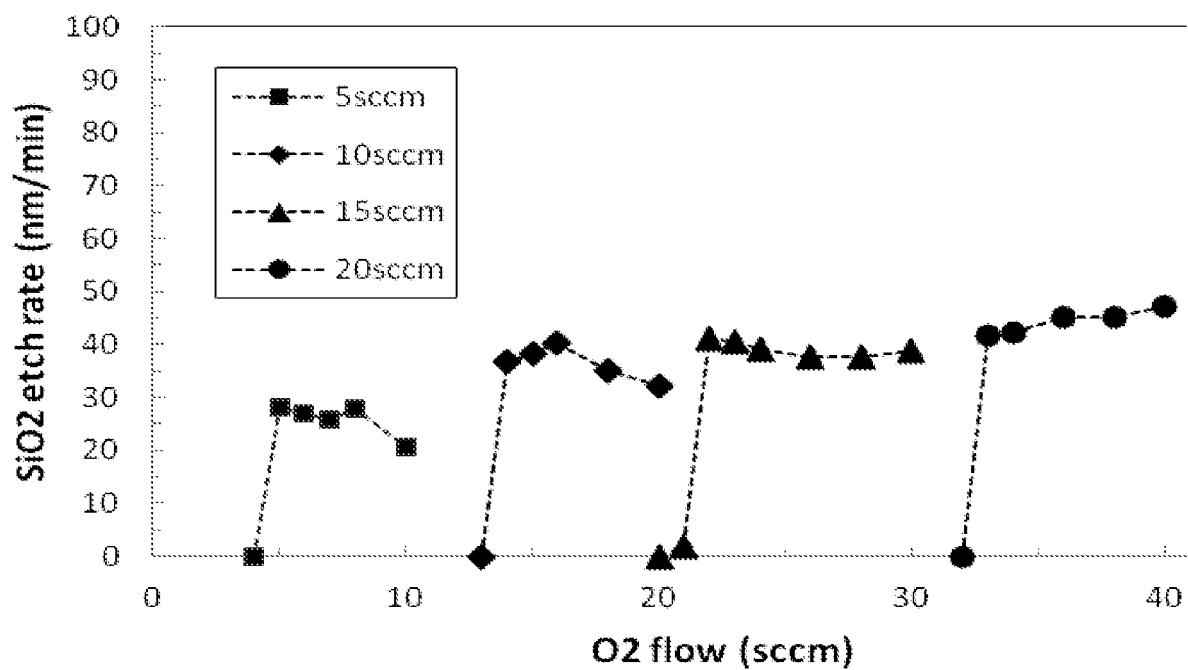
SiO₂ etch rate vs O₂ flow

FIG 16

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Oxide selectivity vs O₂ flow

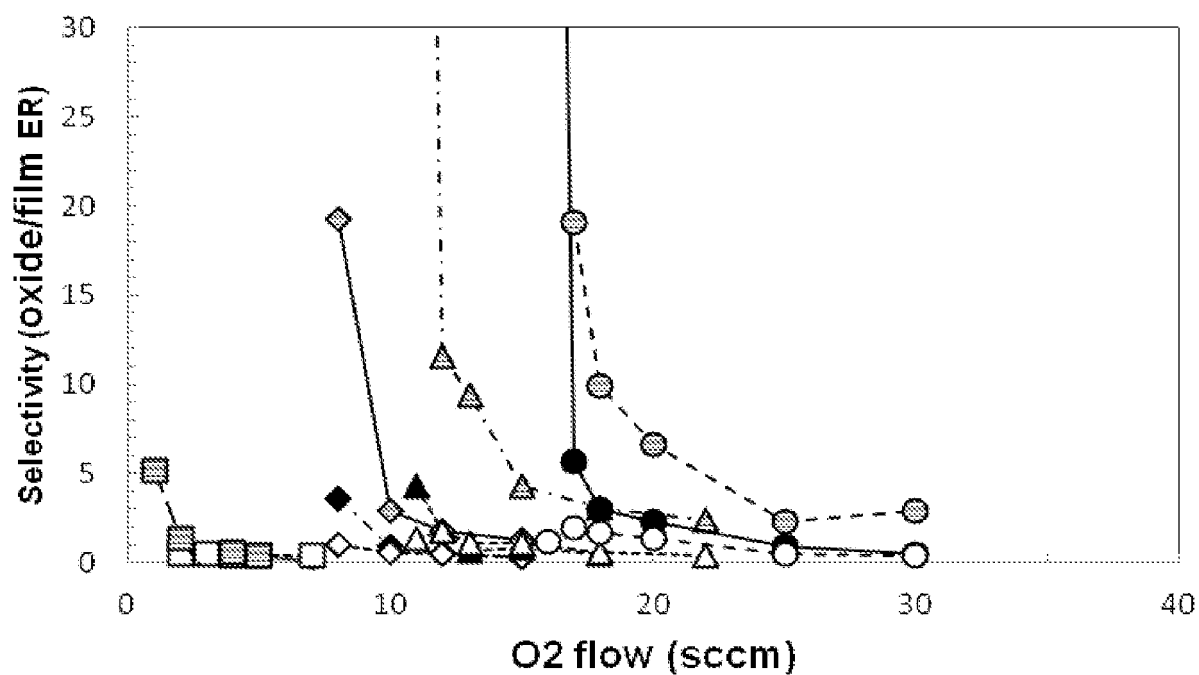


FIG 17

Oxide selectivity vs O₂ flow

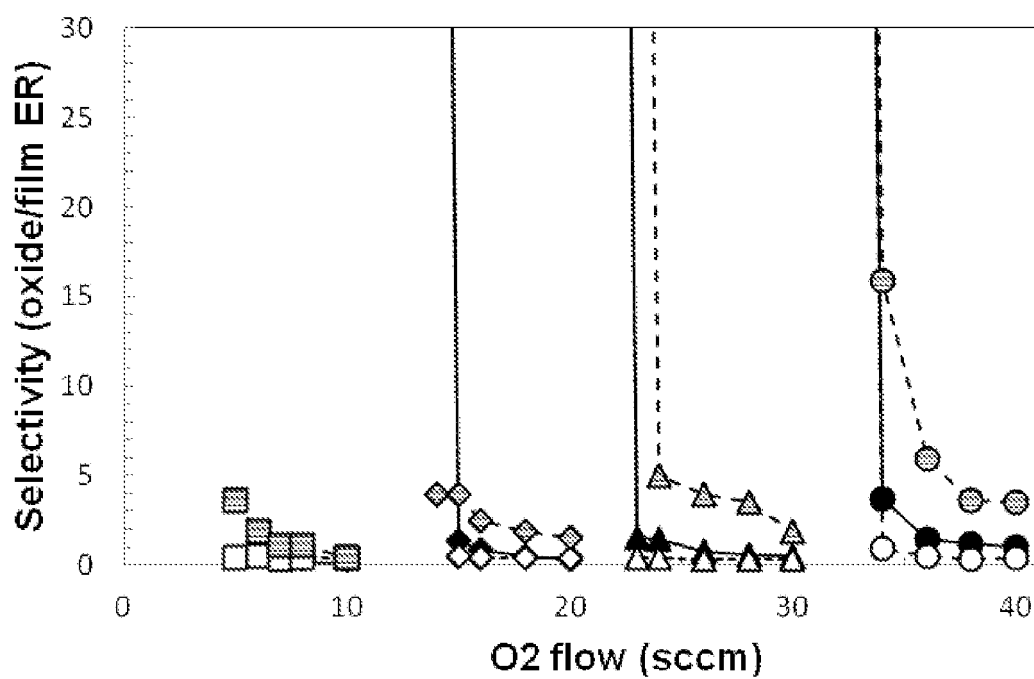


FIG 18

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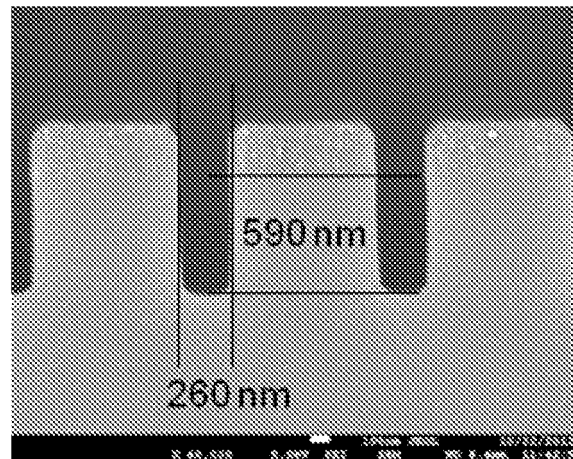


FIG 19

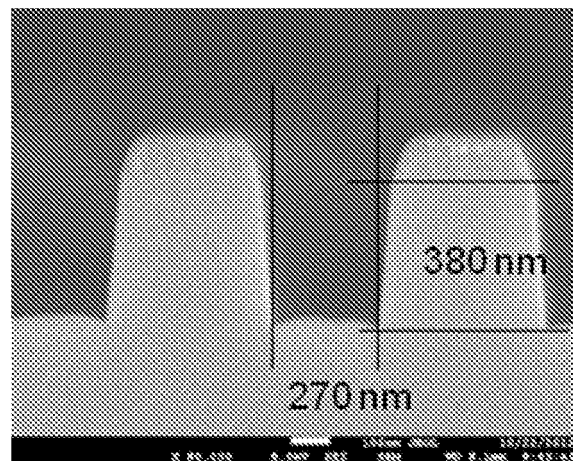


FIG 20

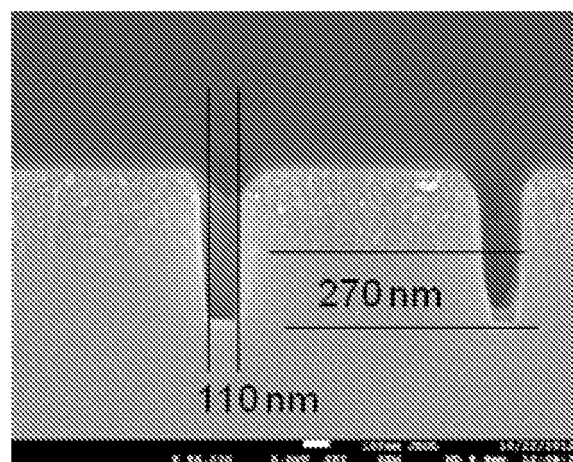


FIG 21

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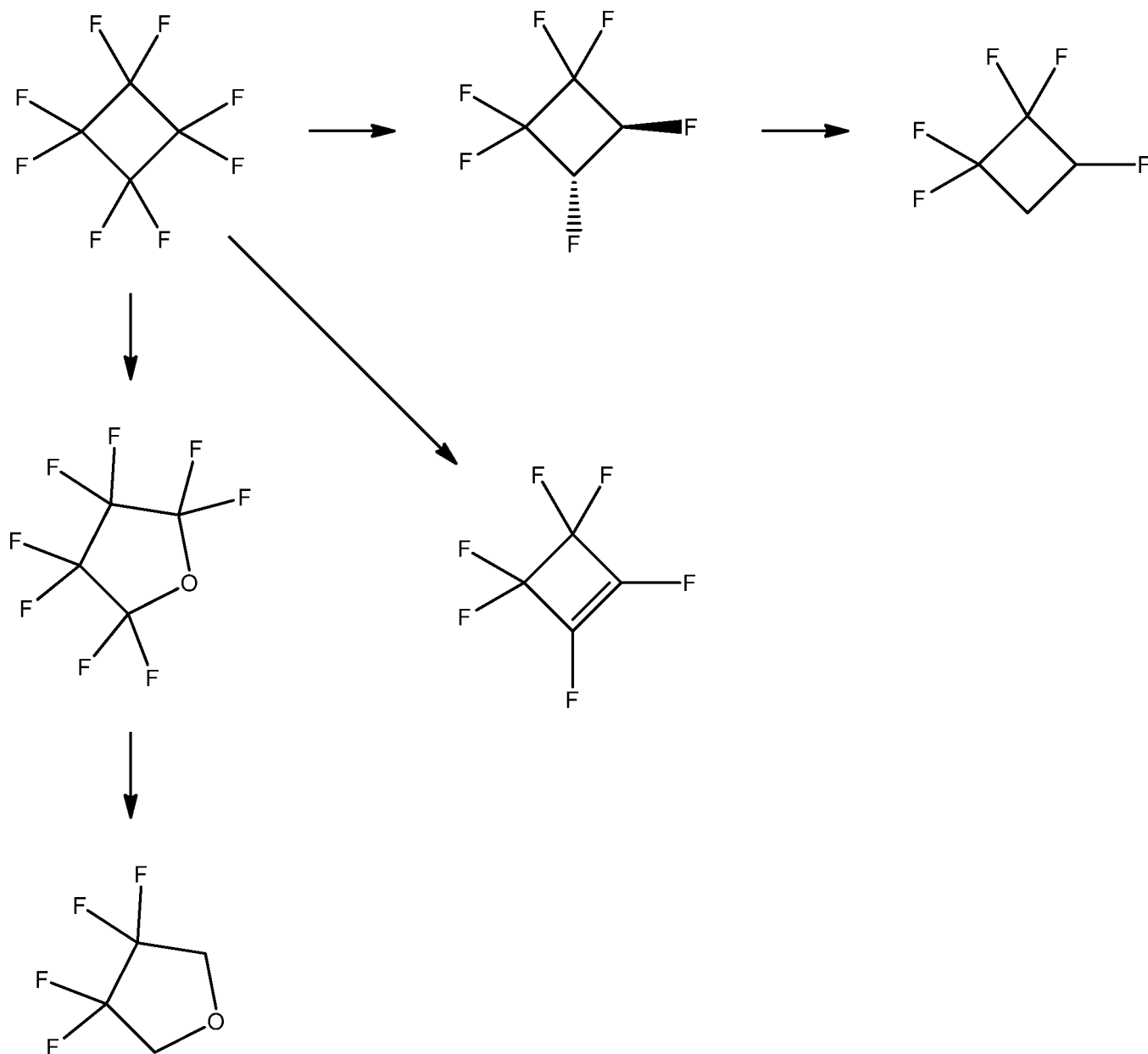


FIG 22